PHOTO TITELLIGENCE MEMORANDUM

SELECTED SHANGHAI INDUSTRIES

GP/I - 100

(Project 71.183)

3 May 1955

DECLASS REVIEW BY NIMA / DoD

CENTRAL INTELLIGENCE AGENCY Office of Research and Reports

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PHOTO INTELLIGENCE MEMORANDUM SELECTED SHANGHAI INDUSTRIES

25X1A 25X1A OCI, for information concerning selected transportation, oil, and shippard installations in the Shanghai area.

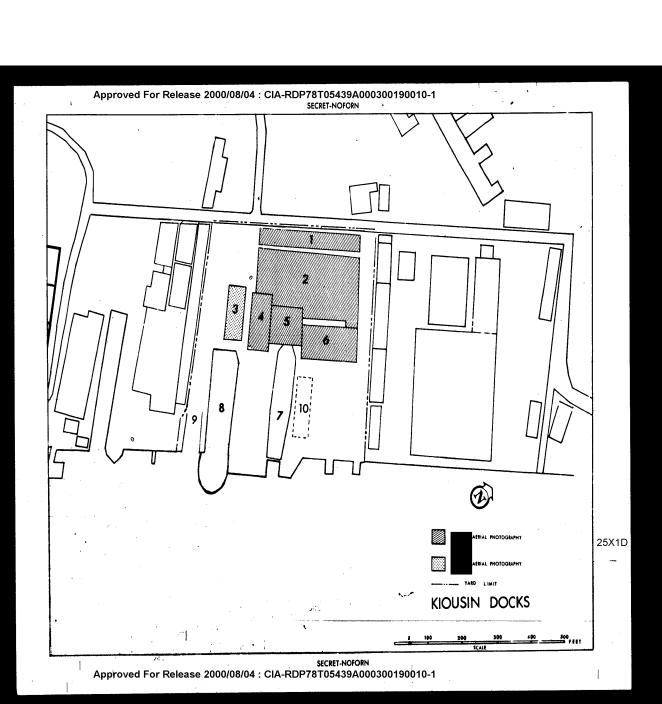
The only suitable aerial photography of this are existed in the Recommaissance Branch of the Air Force (AFOIN-1A2). Because the air Force was currently engaged in exploiting this photography they could not release it, but agreed to supply us with the information we needed.

AFOIN-1A2 was officially requested to supply the information in a letter routed through

The data supplied by the Air Force came through

25X1A

25X1A



S-E-C-R-E-T

Photo Intelligence Memorandum

HAJDUSAG PHARMACEUTICAL FACTORY DEBRECEN, HUNGARY

> GP/I_8 (Project 71.113)

> > 7 June 1954

CENTRAL INTELLIGENCE AGENCY
Office of Research and Reports

S_E_C_R_E_T

HAJDUSAG PHARMACEUTICAL FACTORY DEBRECEN, HUNGARY

reports that the factory is new.

This report is submitted in compliance with a request from OSI/Med for a photo intelligence study of the Penicillin Factory at Debrecen, Hungary.

Detailed photo and ground intelligence searches were made at USAF/ACIC, CD/Graphics Register, and CD/Industrial Register. Four ground photographs were obtained of the installation and are attached hereto. The latest available aerial photography, dated was studied, but none of the structures shown in the ground photography were observed. This substantiates ground intelligence

The results of this interpretation and photogrammetric analysis are forwarded herewith in the form of an artist's sketch prepared by RR/GC under the direction and close supervision of RR/GP. The requested metrical data is annotated on the sketch and may be assumed to be accurate, plus or minus 10%.

25X1D